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P. 01

CERTIFICATE OF TRANSMISSION BY FACSIMILE (37 CFR 1.8)

Applicant(s): Cline et al.

Docket No.

BUR920040122US1

Application No.
10/711,953

Filing Date
10/15/2004

Examiner
Chen, Eric Brice

Group Art Unit
1765

Invention: DEEP TRENCH FORMATION IN SEMICONDUCTOR DEVICE FABRICATION

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I hereby certify that this

Restriction Election (2 pages)

(Identify type of correspondence)

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DOCKET NO.: BUR920040122US1

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s): Cline *et al.*

Examiner: Chen, Eric Brice

Serial No.: 10/711,953

Art Unit: 1765

Filed: 10/15/2004

For: **DEEP TRENCH FORMATION IN SEMICONDUCTOR DEVICE FABRICATION**

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

RESTRICTION ELECTION

In response to the Restriction Requirement dated July 13, 2005, Applicants hereby provisionally elect Group I, claims 1-17, drawn to a method, classified in Class 216, subclass 41. This election is made with traverse, and Applicants hereby reserve the right to file a divisional application in connection with unelected claims 18-20, drawn to a structure.

With regard to the Restriction Requirement, Applicants respectfully submit that the subject matter of all claims 1-20 is sufficiently related that a thorough search for the subject matter of any one group of claims would encompass a search for the subject matter of the remaining claims. Thus, Applicants respectfully submit that the search and the examination of the entire application could be made without serious burden. See MPEP § 803, in which it is stated that "if the search and examination of the entire application can be made without serious burden, the Examiner must examine it on the merits." Applicants respectfully submit that this policy should apply in the present application in order to avoid unnecessary delay and expense to

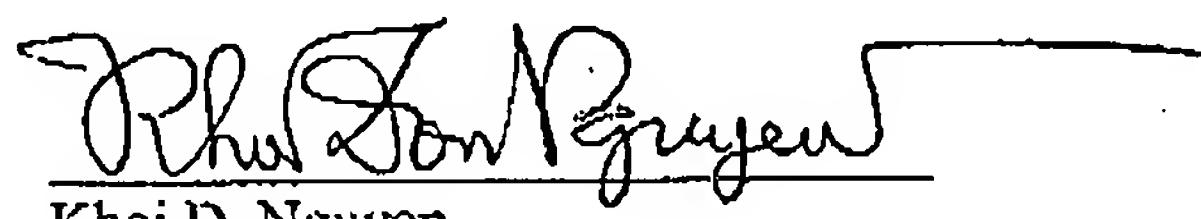
10/711,953

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Applicants and duplicative examination by the Patent Office.

Should the Examiner require or request anything further from Applicants prior to examination, the Examiner is requested to contact Applicants' undersigned representative at the telephone number below. Otherwise, Applicants request early and favorable examination on the merits. The Director is hereby authorized to charge and/or credit Deposit Account No. 09-0456.

Date: August 11, 2005



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